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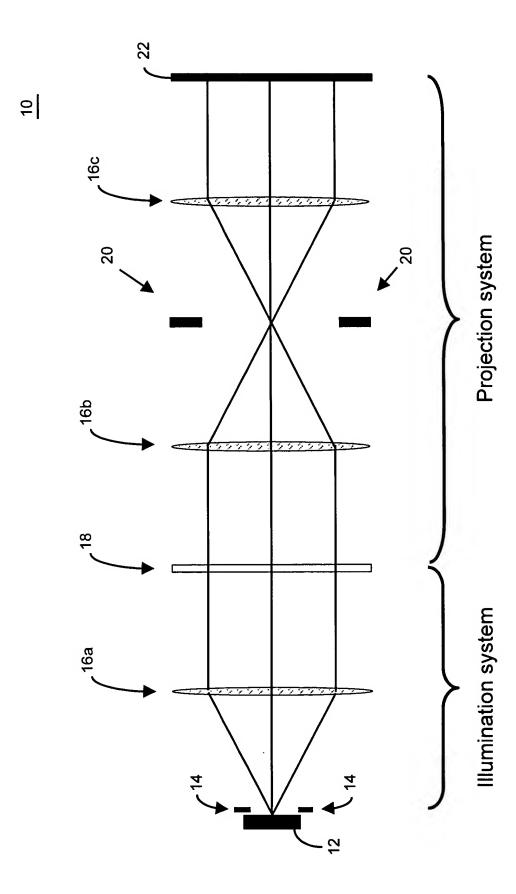
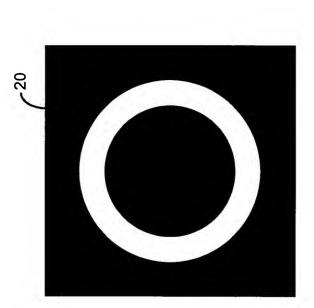


FIGURE 1





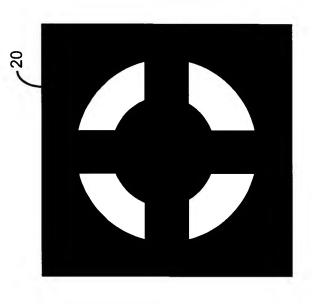


FIGURE 2B

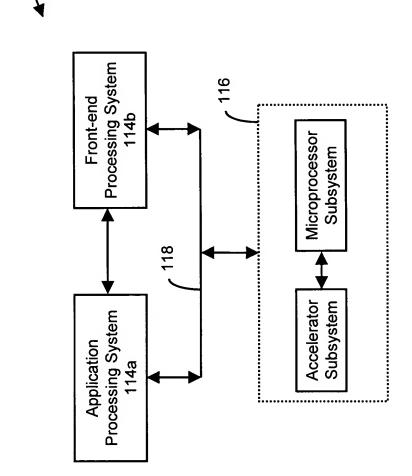


FIGURE 3

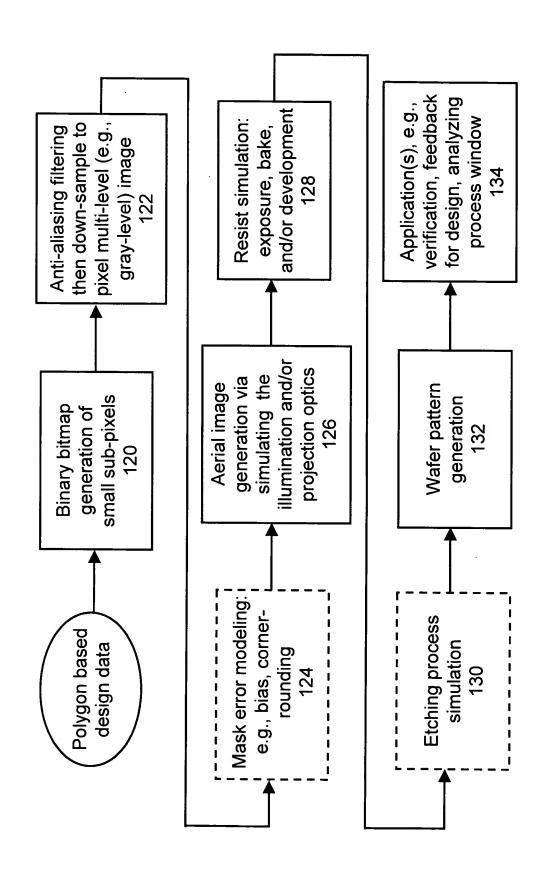


FIGURE 4

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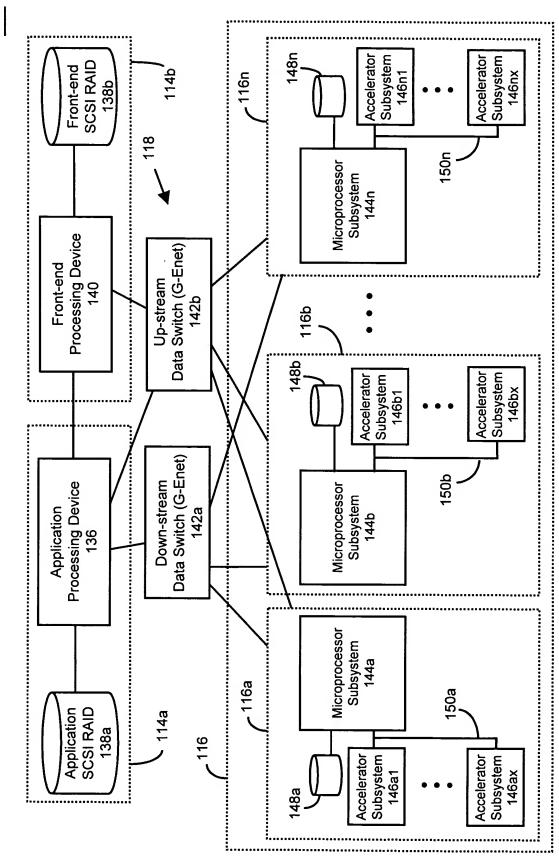
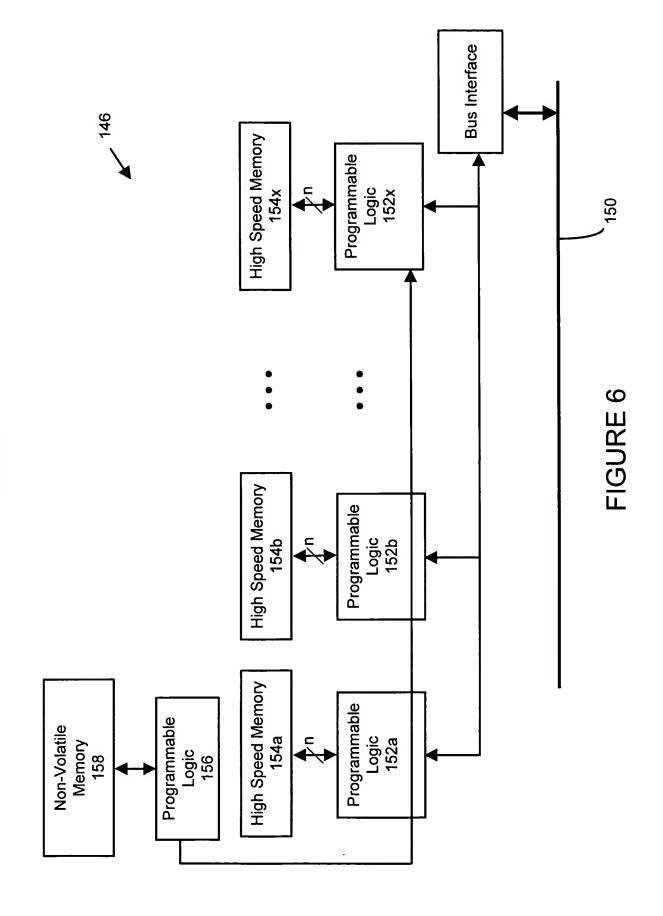


FIGURE 5

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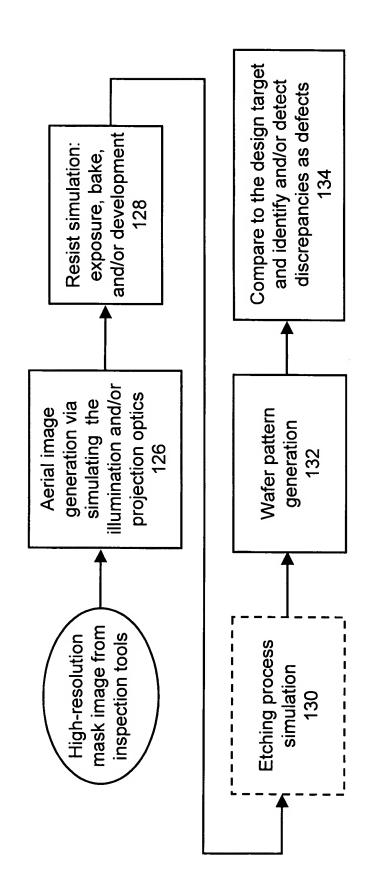


FIGURE 7